Deglitching of 6-Bit, 3-NMOS Pair per Bit Conversion of a DAC under 90nm CMOS Technology Using Sample and Hold Circuitry

¹Mohammed Abdul Muqeet, ²Mohammed Jayeed, ³M.S. Sameera Begum, Electrical Engineering Department, ¹King Khalid University-Abha, KSA, abdulmqt19@gmail.com, ²Buraydah Colleges-Al Qassim, KSA, mhdzaid@gmail.com, ³JNTUH, India, sameera_475@yahoo.com.

Abstract:

The efficiency of digital to analog converter (DAC) is limited due to static and dynamic errors occurred. Many applications urge for the elimination of glitch (the type of dynamic error), hence the need for glitch reduction circuitry. In this paper three architectures for DAC were designed namely Multiplying DAC, Back DAC and String DAC using a pair of three n-type metal oxide semiconductor (NMOS) transistors for 1-bit conversion under 90nm CMOS technology. Glitch refers to the transient activity in the output current during the major carry transition of input code. Sample and hold circuitry is used as a glitch reduction technique. Using this deglitching technique samples were held by allowing the output through an NMOS under 2µm CMOS technology along with a 1pF capacitor. **Keywords:** voltage & current mode DAC, string DAC, Glitch reduction, sample & hold.

I. INTRODUCTION

In today's world, the data or information to be processed is available in analog form, which contradicts the fact that the information acquired can be processed only in its digital counterpart. Hence, there is a vast need for precision converters to fulfil this need. In this paper, various DAC architectures were discussed and designed using NMOS transistors. An appropriate intended design can be obtained by scaling of MOS transistors to meet both speed and complexity. On the other hand, appropriate speed and minimized die area can also be achieved by using floating gate transistors. In [1], using 600nm CMOS technology, the floating gate transistors were visualized as a voltage-gated current source.

The well-known primary DAC is the binary-weighted DAC, which is the simplest but yet not the most efficient to manufacture in high-resolution applications. Another type of DAC referred to its building block structures is the R-2R ladder. This DAC can be designed in two modes, namely voltage mode (Multiplying DAC) and current mode (Back DAC). In voltage mode, the rungs of the ladder are switched between reference voltage and ground, and the output is obtained from the end of the ladder. This DAC is widely used in display driving system applications [2]. Transistor matching is difficult in this type of DAC, and this can be accurately matched by using a compensation circuit and Monte-Carlo simulation [3, 4]. In the current mode, the reference value is provided from the end of the ladder, and the rungs are stretched between output and ground [5, 6].

Another principle architecture used widely is the string DAC architecture. As the name itself illustrates, it uses a stack of resistors to accomplish conversion [7]. This type of architecture requires a large number of resistors, i.e., for N-bit DAC the number of resistors required is 2^N [8]. Modern DAC's usually use a combination of the architectures where there is a need to compromise between precision and speed. Using dual architecture, (one for least significant bits and the other for most significant bits), is referred to as a segmented architecture [9]. On the other hand, most of the DAC's integrated circuits require a combination of the architectures mentioned above due to difficulty in obtaining high speed, high precision, and low cost. Such DAC's are referred to as hybrid DAC's. In [10], slew-rate enhanced class AB output amplifier was used to achieve high speed in hybrid DAC.

Practical implementation of DAC is mainly affected by its non-ideal transfer characteristics. The ideal behaviour is mainly characterized by static and dynamic performance [11]. Static errors mainly affect the accuracy of a converter when it converts the static signals. On the other hand, dynamic errors are the ones that affect the speed, are mainly caused by switching fluctuations. In this paper, the most common dynamic error 'glitch' was studied. Many glitch reduction methods are available, some of which reduces the glitch area but indeed affects the performance of the system. The main source of a glitch is 'major carry switching activity'.

In [12], the gray code method was incorporated for reducing glitch due to the fact that, it switches only 1-input in

a sequence of inputs. Another method is to use first-order low pass filter [13, 14] to calibrate glitch error. Another commonly used method is to use a capacitance compensation filter for segmented architecture [9] using retimed latches [15]. Using carbon nanotube FET (CNFET) in pseudo-segmented structure also reduces glitch and power consumption [16]. In [17], variable delay buffers were used for glitch reduction using current steering DAC. In [18] hybrid wideband R2R LSB segmentation with impedance attenuator was used for glitch reduction. All the methods mentioned above with compensating glitch error also affect the performance of the device in case of gray code technique, whereas some methods compensate the unwanted area in cases of designing an ideal filter. In this paper, a sample and hold (S&H) circuitry was used [19] to reduce the glitch error that suffice the need for reducing glitch without affecting the performance of the circuit.

II. DAC ARCHITECTURES

In this paper, the design of three architectures for a 6-bit input sequence was accomplished with and without the glitch reduction technique, and the simulation results were compared to justify the efficiency of the design. With the basic R-2R design, it is always possible to generate either a voltage output or current output. Generation of voltage output requires an additional output buffer whereas for output current no output buffer is required. In this paper, all the circuits are designed to generate an output current.

A. 6-BIT MDAC ARCHITECTURE

MDAC architecture is the most flexible building block providing efficient design specifications. In this design, for each bit conversion, 3-NMOS transistor pairs under 90nm technology were used. Inconsistent with the traditional design of an MDAC in R-2R configuration, the implemented design for each bit operation consists of two rungs. The NMOS transistors in both the rungs were designed to operate in the triode region, whereas the third NMOS transistor operates in either weak-inversion region or active region based on the digital (LOW/HIGH) input provided for conversion expressed by the equation (1).

The transistors in the circuit are designed under 8:1 and 4:1 equivalency for the parameter W/L ratio to achieve appropriate matching considerations which are shown in Table-1 along with the design considerations. The implemented circuit for MDAC is shown in Figure-1. MDAC is a low noise DAC that uses various reference voltages at every bit conversion. The output current I_{out} was measured which was found to be proportional with the digital input code (D_0-D_5) as shown in Figure-4(a).



Figure-1: 6-bit MDAC

TABLE-1 DESIGN CONSIDERATIONS

Paramet er	MDAC	Back DAC	String DAC	S&H
V _{ref}	5V	5V	5V	-
Vg	7.5V	7.5V	7.5V	-
Varied V _{ref}	5V (MSB) – 4.8V (LSB)	5V (MSB) – 4.8V (LSB)	5V (MSB) - 4.8V (LSB)	-
NMOS in linear Region	Q1,Q3, Q4,Q6,Q7, Q9,Q10,Q12 ,Q13, Q15,Q16,Q1 8	Q1,Q3, Q4,Q6,Q7, Q9,Q10,Q1 2,Q13, Q15,Q16,Q 18	Q1 throug h Q12	-
NMOS in Cutoff /Saturatio n Region	Q2,Q5, Q8,Q8, Q11,Q14, Q17	Q2,Q5, Q8,Q8, Q11,Q14, Q17	Q13 throug h Q18	-
W/L ratio	8:1(Linear) 4:1(Cutoff/ Saturation)	8:1 (Linear) 4:1(Cutoff/ Saturation)	4:1	10:1
$T_P \ T_r \ T_f$	-	-	-	20ms 10μs 10μs
V _m	-	-	-	10V
C	-	-	-	1pF

B. 6-BIT BACK DAC ARCHITECTURE

In general, a back DAC finds its place in instrumentation and digitally controlled calibration applications. Both the back DAC and MDAC are analog

circuits with a small difference in the digital control logic. All the NMOSes used for bit conversion are designed under 90nm technology. In the designed circuit, 3 transistors were used per bit conversion. The NMOS transistors in both the rungs were designed to operate in the triode region, whereas the third NMOS transistor operates in either weak-inversion region or active region based on the digital (LOW/HIGH) input provided for conversion as expressed in equation (1). The transistors in the circuit are designed under 8:1 and 4:1 equivalency for the parameter W/L ratio to achieve appropriate matching considerations, which is shown in along with the design considerations. The Table-1 implemented circuit for back DAC is shown in Figure-2. The design considerations are shown in Table-1. The output current I_{out} versus digital input code is shown in Figure-4(b).



Figure-2: 6-bit Back DAC

C. 6-BIT STRING DAC ARCHITECTURE

The string architecture also uses NMOS transistors stacked together in an orderly manner to achieve the design as shown in Figure-3. The transistors $Q_1 - Q_{12}$ are designed to operate in triode region whereas the transistors $Q_{13} - Q_{18}$ operates in either weak-inversion region or active region based on the digital (LOW/HIGH) input provided for conversion as expressed in equation (1). The transistors in the circuit are designed under 4:1 equivalency for the parameter *W/L* ratio to achieve appropriate matching considerations, which is shown in Table-1 along with the design considerations.

String DAC's are widely used due to their properties such as monotonic nature, smallest die area, and low-cost design. This type of architecture provides the lowest glitch area as compared to other two R-2R architectures mentioned in this paper.



Figure-3: 6-bit string DAC

The output current I_{out} versus digital input code is shown in Figure-4(c).



Figure-4: I_{out} without glitch reduction technique. (a)MDAC, (b) Back DAC and (c) String DAC.

D. R2R DAC WITH S&H CIRCUITRY

The most common dynamic errors that affect the performance of a DAC are the glitch and settling time. Glitches are mainly experienced due to the switching activity from the incoming digital code, which causes a momentary surge in current. The nature of glitch is assumed as a step response consisting of glitch area and settling time. In practical DAC's, the glitch is often experienced when switching the digital input code from 00001111 to 00010000 and 00011111 to 00100000. In this paper, Sample and Hold(S&H) circuit was used to reduce the glitch area. The obtained analog signal was sampled using an NMOS transistor Q_I under 2µm technology with 10:1 *W/L* ratio.

A gate voltage was applied using a step input source with pulse time, $T_p=20ms$ and rise and fall time of $T_r=T_f=10\mu s$. A 1pF output capacitor was used to hold the output current as shown in Figure-4.



Figure-5: Sample and Hold Circuitry

Glitch area is a measure of the area under transition of the output of DAC. In this paper, the glitch area(A) was computed by partitioning the glitch duration, i.e., the time interval determining the start and end occurrences of a glitch into subintervals N as expressed in equation (2) for the specified glitch amplitude h_i at a specified interval w_i .

$$A = \sum_{i=1}^{N} h_i w_i \tag{2}$$

The net glitch area refers to the summation of individual glitch area. The net glitch was calculated without and with glitch reduction technique for all the three architectures mentioned in this paper. The output current I_{out} from glitch reduction circuitry versus digital input code is shown in figure-6.



Figure-6: I_{out} with glitch reduction technique. (a)MDAC, (b) Back DAC and (c) String DAC.

DAC	Glitch occurrence	Net Glitch Area		
		W/O S&H	With S&H	
MDAC	$\begin{array}{c} 001111 \rightarrow 010000, \\ 011111 \rightarrow 100000, \\ 101111 \rightarrow 110000 \end{array}$	51nA	12nA	
Back DAC	$\begin{array}{c} 000011 \rightarrow 000100, \\ 000111 \rightarrow 001000, \\ 001111 \rightarrow 010000, \\ 011111 \rightarrow 100000, \\ 101111 \rightarrow 110000 \end{array}$	655nA	386.5nA	
String DAC	$\begin{array}{c} 000111 \rightarrow 001000, \\ 001111 \rightarrow 010000, \\ 010111 \rightarrow 011000, \\ 101111 \rightarrow 110000 \end{array}$	15nA	14.5nA	

Table-2: Net Glitch Area.

III. CONCLUSION

A novel deglitching method for R-2R DAC architectures was proposed. Experimental results validate the glitch reduction method of sample and hold circuit. Significant glitch reduction was observed in all the DAC architectures designed. It was observed experimentally that the net glitch area was reduced by 76.5% in MDAC, 41% in Back DAC and 3.4% in string DAC. Also, it was observed that the string DAC possess the least net glitch area without deglitching method.

ACKNOWLEDGMENT

The authors would like to thank King Khalid University, Abha, KSA and Buraydah Colleges for supporting and encouraging this work.

REFERENCES

[1] G.Serrano, et al., "A Gloating-Gate DAC Array" in IEEE ISCAS 2004, Volume I (IEEE Cat. No.04CH37512).

[2] Tai-Cheng Lee et al., "Nonlinear R-2R Transistor-Only DAC" in IEEE transactions on circuits and systems, Vol.57, No.10, October 2010.

[3] David Fitrio et al., "Ultra Low Power Weak Inversion Current Steered Digital to Analog Converter" in IEEE Transactions, APCCAS 4-7 Dec. 2006, ISBN: 10.1109/APCCAS.2006.342537.

[4] Jose Bastos et al., "A High Yield 12-bit 250MS/s CMOS D/A Converter" in IEEE Custom Integrated Circuits conference 06 August 2002. ISBN: 0-7803-3117-6.

[5] Vivian W.K Shen et al., "Data Acquisition and Conversion" in IEEE International Solid-State Circuits Conference, 1983.

[6] Dimitris Karadimas et al., "A MOST-Only R-2R Ladder based architecture for High Linearity DACs" in IEEE transaction, 03 September 2008. ISBN: 10203645.

[7] Surajit Bari et al., "Design of resistor string digital to analog converter using nano-dimensional MOS transistor for low power and high-speed circuit application" in IEEE Journal of Devices for Integrated Circuits(DevIC), March 2017.

[8] Mikhail S. et al., "A 10-bit Segmented M-String DAC" in IEEE Conference of Russian Young Researchers in Electrical and Electronic Engineering (EIConRus) 15 March 2018.

[9] Feng Ye et al., "A 14-bit 2GS/s DAC with a Programmable Interpolation Filter" in IEEE 11th International Conference on ASIC (ASICON) July 2015, **Electronic ISSN:** 2162-755X.

[10] Bill Ma et al., "A 12-bit 1.74mW 20MS/s DAC with Resistor-String and current steering Hybrid Architecture" in 28th IEEE International System-on-Chip Conference (SOCC) 15 February 2016. Electronic ISSN: 2164-1706.

[11] J De Maeyer et al., "Addressing Static and Dynamic Errors in Band pass unit Element Multibit DACs" in IEEE International Symposium on Circuits and Systems (IEEE Cat. No.04CH37512) 03 September 2004. **Print ISBN:** 0-7803-8251-X.

[12] Gopal Adhikari et al., "Study of Gray Code Input DAC using MOSFETs for Glitch Reduction" in IEEE (ICSICT) 03 August 2017.

[13] B.Catteau et al., "A Digital Calibration Technique for the Correction of Glitches in High-Speed DACs" in IEEE International Symposium on Circuits and Systems 25 June 2006. **ISBN:** 1-4244-0920-9.

[14] K.OlaAndersson et al., "Modeling of Glitches due to Rise/Fall Asymmetry in Current-Steering Digital-to-Analog Converters" in IEEE Transactions on Circuits and Systems, Vol.52, NO.11, NOVEMBER 2005.

[15] Fang-Ting Chou et al., "Glitch Energy Reduction and SFDR Enhancement Techniques for Low-Power Binary Weighted Current-Steering DAC" in IEEE Transactions on Very Large Scale Integration (VLSI) Systems, VOL.24, NO.6, 2016.

[16] P.Moslehi et al., "A 10-bit 1GS/s current-steering DAC with Carbon Nanotube Field Effect Transistor (CNFET)" in IEEE(ICDCS), April 2012.

[17] Fang-Ting Chou et al., "A Novel Glitch Reduction Circuitry for Binary-Weighted DAC" in IEEE (APCCAS) February 2015.

[18] Sang Min Lee et.al, "A 14b 750MS/s DAC in 20nm CMOS with 168dbm/Hz noise floor beyond Nyquist and 79dbc SFDR utilizing a low glitch-noise hybrid R-2R architecture" in Symposium on VLSI Circuits Digest of Technical Papers, 2015.

[19] K.Khanoyan et al., "A 10b, 400MS/s Glitch-Free CMOS D/A Converter" in Symposium on VLSI Circuits Digest of Technical Papers, 1999.